

<b>INFORMATION DISCLOSURE STATEMENT</b>			Atty Docket: Serial No.: Applicant: Filing Date: Group:		02GR102454481 Not Yet Assigned Gris Herewith		
<b>U.S. PATENT DOCUMENTS</b>							
Examiner Initials		Document Number	Date	Name	Class	Sub Class	Filing Date
<i>BSKS</i>	AA	6,358,809	3/19/02	Nobinger et al.	438	382	
	AB						
	AC						
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						
	AL						
	AM						
<b>FOREIGN PATENT DOCUMENTS</b>							
		Document Number	Date	Country	Class	Sub Class	Translation
<i>BSKS</i>	AN	0167851	1/15/86	EP	H01L21	66	
	AO						
	AP						
	AQ						
<b>OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)</b>							
<i>BSKS</i>	AR	Patent Abstracts of Japan, Vol. 017, No. 475 (C-1103), August 30, 1993 & JP 05117088A (Sumitomo Electric Ind. Ltd.), May 14, 1993					
<i>BSKS</i>	AS	Hutchings, Localized Semiconductor Diffusions Utilizing Local Laser Melting in Doping Atmospheres, January 1974, IBM Technical Disclosure Bulletin, Vol. 16, No. 8, January 1, 1974, Pages 2585-2586, XP002246185					
	AT						
<b>EXAMINER:</b> <i>BSKS</i>				<b>DATE CONSIDERED:</b> <i>2/20/05</i>			

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.